## **Photopolymer Plate Processing Equipment**

3ES-PROIII-ETLDi

Top lift Double Side Exposure (Back&Main)

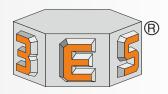












Plate exposing equipment for photopolymer plates up to a maximum size of 1060 x 1530 mm.

- Capable of exposing (back & main) and finishing/post-exposing\* all high quality photopolymer plates at high dot resolution, excellent line definition, deep reverses repeatable results for both back and main exposures to meet the highest HD Flexo standard
- High power UV-A lamps for high quality at high speed
- Easy to operate, install and maintain
- User-friendly 7" touch screen operation panel displays all necessary times and settings
- 20 programmable channels for different plates process conditions
- The top lid opens/closes smoothly and completely, it makes easier to reach all four sides of the plate.
- Provides both main and back exposure at once without moving plate due to the glass bed
- Suitable for all digital and analogue plates
- Lamp life time calculator
- Defective lamp indicator
- Lamp temperature control and regulation
- Yellow inspection lamp
- Electronic ballast
- End of job alert.

\*Optional

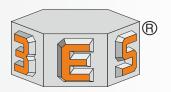






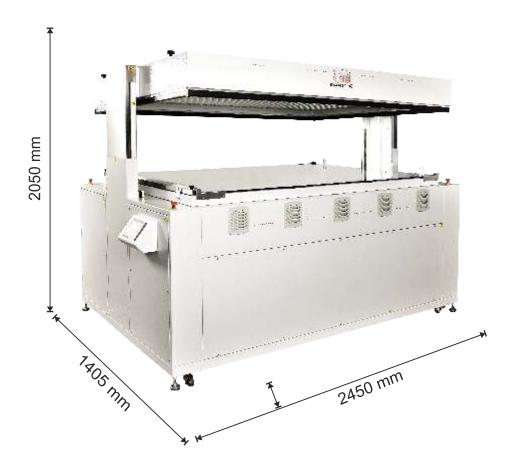
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3ES-PROIII-ETLDi Top lift Double Side Exposure (Back&Main)



## Technical Data

Product Name	3ES-PROIII-ETLDi
Maximum Plate Size	1060*1530 mm (41.7" x 60")
Plate Type	Analog & Digital Plates
Exhaust (Light Finisher)	Ø100 mm
Compressed Air	7 bar minimum
<b>Environmental Requirements</b>	Temperature: 15°C to 30°C Humidity: 40% -60%
Power	10 kW 16A 400 V AC (3 Ph/N/PE)50/60 Hz
Crate Dimension (approx.)	2550*1505*1400 mm
Weight	1120 kg net / 1450 kg gross



For all other information's or request please contact Mega.....

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